

**IN THE SPECIFICATION**

**Please rewrite the paragraph on page 31, lines 16-24, as follows:**

Because of the repeated irradiation of the Nd:YAG laser beam to the poly-Si film 203A, the irradiated parts of the film 203A are selectively removed due to “ablation”. Thus, unlike the first embodiment, the alignment marks are generated by the hollow regions 205 of the film 203A. In the first embodiment, the irradiated regions 105 are solid because they are not removed due to ablation. Similar to the first embodiment, the alignment marks may be generated by the hollow irradiated regions ~~105~~ 205 of the film ~~103~~ 203A.

**Please rewrite the paragraphs on page 33, lines 7-24, as follows:**

The optical beam emitted from the excimer laser 211 is selectively irradiated to specific areas of the poly-Si film 303A in the form of pulse in the step-and-repeat manner. The irradiation of the said beam is repeated three times (i.e., three shots) in each of the areas. Thus, rectangular irradiated regions 304 are formed in the poly-Si film ~~303~~ 303A, as shown in Fig. 5C. The poly-Si regions ~~504~~ 304 are regularly arranged along the X and Y axes.

Subsequently, the optical beam emitted from the double-frequency Nd:YAG pulse laser 214 is selectively irradiated to the poly-Si film ~~303~~ 303A in the form of pulse in the step-and-repeat manner. The irradiation of the said beam is repeated 30 times (i.e., 30 shots) in each of the areas. Thus, dot-shaped irradiated regions 305 are formed in the corresponding poly-Si regions 304A, as shown in Fig. 5C. Each of the poly-Si regions 305 is located in (i.e., overlapped with) a corresponding one of the poly-Si regions 304, where the edges of the region 305 are aligned with the corresponding edges of the region 304.

**Please rewrite the paragraph on page 37, lines 12-14, as follows:**

Similar to the second embodiment, the alignment marks may be generated by the ~~hollow~~  
solid irradiated regions 405 in the said fourth embodiment as well.